Name: OPTion – Quality process for a Pattern Repository for teaching and learning practice

Abstract:
OPTion provides a platform for a didactic pattern repository, that helps to includes a quality standard within proven solutions for teaching and learning. Didactic Pattern are published in various journals, books, conference papers and website. Even these are published pattern and should follow one systematic, the users can’t make a statement about quality aspects. It’s difficult to recognize if the pattern was written within a quality process. With the process provided by the repository OPTion, we want to ensure quality standards for the documentation, research, dissemination and transfer of proven teaching and learning solutions. With standardized taxonomies develop during the process, it will be possible to set filter for finding an adequate quality pattern for a transfer into teaching and/or research opportunities.

Outcomes:
In a focus group, we would like to promote our idea of the four quality steps within the process for didactic pattern in Higher Education. It is a challenge to create a platform with a specific systematic, which represents both an adequate (and intuitively usable) instrument for the different requirements throughout the whole process. The Tool should ensure sustainability through all quality aspects and the transfer into teaching and learning practice. We would like to discuss: How participants and users can assess a sufficient quality standard exists in the process? Would our idea of implanting a systematic Tool for didactic pattern work? We would like to find answers together with the participants, how we ensure quality standards in each step of the process.

Focus Group Structure:
MaxParticipants:
3 participants * 4 groups (12 participants)
Time:
15 Minutes: Explaining our idea of a repository  
35 Minutes: "Workshop" Discussion in small groups  
25 Minutes: Feedback and Discussion (full group)

For further information, please visit our platform:  
www.patternpool.de